

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	1546	359/649-651,708,713,754,756,757,800.ccls.	USPAT; US-PGPU B; EPO; 2002/ JPO; 11/22 DERWENT ; IBM_TDB	18:02
2	BRS	L2	3539	355/53,67.ccls.	USPAT; US-PGPU B; EPO; 2002/ JPO; 11/22 DERWENT ; IBM_TDB	18:02
3	BRS	L3	1563	356/399,400.ccls.	USPAT; US-PGPU B; EPO; 2002/ JPO; 11/22 DERWENT ; IBM_TDB	18:02
4	BRS	L4	976	250/203.7,548.ccls.	USPAT; US-PGPU B; EPO; 2002/ JPO; 11/22 DERWENT ; IBM_TDB	18:02
5	BRS	L5	7167	1 or 2 or 3 or 4	USPAT; US-PGPU B; EPO; 2002/ JPO; 11/22 DERWENT ; IBM_TDB	18:03

	Type	L #	Hits	Search Text	DBs	Time Stamp
6	BRS	L6	6136	project\$5 near5 objective\$2	USPAT; US-PGPU B; EPO; 2002/ JPO; 11/22 DERWENT 18:03 ; IBM_TDB	
7	BRS	L7	1264061	(micro-lithograph\$4 or microlithograph\$4 or (micro adj2 lithograph\$4)) or (exposure or exposing or expose\$2)	USPAT; US-PGPU B; EPO; 2002/ JPO; 11/22 DERWENT 18:05 ; IBM_TDB	
8	BRS	L8	497984	lens or lenses or lensing	USPAT; US-PGPU B; EPO; 2002/ JPO; 11/22 DERWENT 18:05 ; IBM_TDB	
9	BRS	L9	19198	aspheric\$ or non-spheric\$	USPAT; US-PGPU B; EPO; 2002/ JPO; 11/22 DERWENT 18:06 ; IBM_TDB	
10	BRS	L1 0	88	6 and 7 and 8 and 9	USPAT; US-PGPU B; EPO; 2002/ JPO; 11/22 DERWENT 18:07 ; IBM_TDB	

	Document ID	Source	Issue Date	Pages	Title	Current OR	Current XRef
1	WO 9828644 A1	<input checked="" type="checkbox"/> E P O	1998 0702	26	RETICULAR OBJECTIVE FOR MICROLITHOGRAPHY-PROJ ECTION EXPOSURE INSTALLATIONS		
2	US 6259508 B1	<input checked="" type="checkbox"/> U S P A T	2001 0710	29	Projection optical system and exposure apparatus and method	355/53	355/67; 359/766
3	US 20020122164 A1	<input checked="" type="checkbox"/> U S - P G P U B	2002 0905	12	Lithographic objective having a first lens group including only lenses having a positive refractive power	355/67	355/53; 355/55; 359/733 ; 359/734 ; 359/736
4	US 6366410 B1	<input checked="" type="checkbox"/> U S P A T	2002 0402	8	Reticular objective for microlithography-proj ection exposure installations	359/649	359/656 ; 359/726

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1	BRS	L1	1546	359/649-651,708,713,754,756,757,800.ccls.	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/ 11/22 18:02
2	BRS	L2	3539	355/53,67.ccls.	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/ 11/22 18:02
3	BRS	L3	1563	356/399,400.ccls.	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/ 11/22 18:02
4	BRS	L4	976	250/203.7,548.ccls.	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/ 11/22 18:02
5	BRS	L5	7167	1 or 2 or 3 or 4	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/ 11/22 18:03

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6	BRS	L6	6136	project\$5 near5 objective\$2	USPAT; US-PGPU B; EPO; 2002/ JPO; 11/22 DERWENT 18:03 ; IBM_TDB	
7	BRS	L7	1264061	(micro-lithograph\$4 or microlithograph\$4 or (micro adj2 lithograph\$4)) or (exposure or exposing or expose\$2)	USPAT; US-PGPU B; EPO; 2002/ JPO; 11/22 DERWENT 18:05 ; IBM_TDB	
8	BRS	L8	497984	lens or lenses or lensing	USPAT; US-PGPU B; EPO; 2002/ JPO; 11/22 DERWENT 18:05 ; IBM_TDB	
9	BRS	L9	19198	aspheric\$ or non-spheric\$	USPAT; US-PGPU B; EPO; 2002/ JPO; 11/22 DERWENT 18:59 ; IBM_TDB	
10	BRS	L1 0	88	6 and 7 and 8 and 9	USPAT; US-PGPU B; EPO; 2002/ JPO; 11/22 DERWENT 18:59 ; IBM_TDB	

	Type	L #	Hits	Search Text	DBs	Time Stamp
11	BRS	L1 1	20102	aspheric\$ or non-spheric\$ or nonspheric\$	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/ 11/22 18:59
12	BRS	L1 2	96	6 and 7 and 8 and 11 .	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/ 11/22 18:59
13	BRS	L1 3	8	12 not 10	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/ 11/22 18:59